

PROCEEDINGS OF SPIE

3D Printed Optics and Additive Photonic Manufacturing IV

**Alois M. Herkommer
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Editors

**8–9 April 2024
Strasbourg, France**

Sponsored by
SPIE

Cooperating Organisations
Photonics 21 (Germany)
EOS—European Optical Society

Published by
SPIE

Volume 12995

Proceedings of SPIE 0277-786X, V. 12995

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

3D Printed Optics and Additive Photonic Manufacturing IV, edited by Alois M. Herkommer,
Georg von Freymann, Manuel Flury, Proc. of SPIE Vol. 12995, 1299501
© 2024 SPIE · 0277-786X · doi: 10.1117/12.3037415

Proc. of SPIE Vol. 12995 1299501-1

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Please use the following format to cite material from these proceedings:
Author(s), "Title of Paper," in *3D Printed Optics and Additive Photonic Manufacturing IV*, edited by Alois M. Herkommer, Georg von Freymann, Manuel Flury, Proc. of SPIE 12995, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510673083
ISBN: 9781510673090 (electronic)

Published by
SPIE
P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time)
SPIE.org
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